Influence of Gd Doping on the Structure and Electrochemical Behavior of UO2

Nazhen Liu\textsuperscript{a}, Jandee Kim\textsuperscript{b}, Jeongmook Lee\textsuperscript{b}, Young-Sang Youn\textsuperscript{b}, Jong-Goo Kim\textsuperscript{b}, Jong-Yun Kim\textsuperscript{b,c,∗}, James J. Noël\textsuperscript{a,d}, David W. Shoesmith\textsuperscript{a,d,∗}

\textsuperscript{a} Department of Chemistry, The University of Western Ontario, London, Ontario, N6A 5B7, Canada
\textsuperscript{b} Nuclear Chemistry Research Division, Korea Atomic Energy Research Institute, Daejeon, 34057, Republic of Korea
\textsuperscript{c} Radiochemistry & Nuclear Nonproliferation, University of Science & Technology, Daejeon, 34113, Republic of Korea
\textsuperscript{d} Surface Science Western, The University of Western Ontario, London, Ontario, N6G 0J3, Canada

Abstract

A series of (\textit{U}_{1-x}\textit{Gd}_{x})\text{O}_2 materials (\textit{x}=0, 0.01, 0.03, 0.05, 0.07 and 0.10) were characterized by X-ray diffractometry and Raman spectroscopy to determine the influence of Gd\textsuperscript{III} doping on the structure of (\textit{U}_{1-x}\textit{Gd}_{x})\text{O}_2 solid solutions. The XRD results show that, while the fluorite structure is maintained, Gd doping up to 10\% leads to a contraction of the fluorite lattice. Raman spectroscopy shows Gd\textsuperscript{III} doping distorts the fluorite lattice structure due to the formation of oxygen vacancies (\textit{O} \textsuperscript{−}) and, possibly, MO\textsuperscript{2−} type complexes, as a consequence of the differences in both the oxidation state and the ionic radius of Gd\textsuperscript{III} compared to that of the U\textsuperscript{VI}. The influence of Gd doping on the electrochemical reactivity of the (\textit{U}_{1-x}\textit{Gd}_{x})\text{O}_2 specimens was shown to be minor, possibly due to a competition between the increase in the number of \textit{O} \textsuperscript{−} and the contraction of the lattice.

1. Introduction

The recommended approach for the long-term management of used nuclear fuel in Canada is adaptive phased management [1, 2]. As accepted internationally, the repository concept is based on multiple barriers including the fuel bundles, durable metal containers, a clay buffer and seals around the container, and a deep geologic environment [3]. A key barrier is the corrosion-resistant container that will be designed to isolate the used fuel indefinitely [4, 5]. However, it is judicious to examine the consequences of container failure and the exposure of used fuel bundles to groundwater. Since U is considerably more soluble in the oxidized (\textit{U}^{VI}) than the reduced form (\textit{U}^{IV}) [6], its dissolution, leading to the release of radionuclides, must proceed via corrosion. In the anoxic conditions anticipated in a deep geological repository, water radiolysis, resulting from the radiation fields associated with the used fuel, will be the only source of oxidants. Of the oxidants formed by radiolysis, H\textsubscript{2}O\textsubscript{2} has been shown to be the primary oxidant driving fuel corrosion [7, 8].

The reactivity of the UO\textsubscript{2} matrix, and how it is modified by in-reactor irradiation, is important in determining fuel corrosion. The key changes likely to influence the chemical reactivity of the fuel are the rare earth (RE) doping of the matrix, the presence of noble metal particles and the development of non-stoichiometry [9]. Considerable experimental evidence exists to show that fission product and actinide-lanthanide doping have a significant effect on the kinetics of air oxidation of the fuel [10, 11]. Choi et al. investigated the oxidation of UO\textsubscript{2} based SIMFUEL (1.5, 3.0, 4.0, 6.0 and 8.0 at\%), and showed that oxidation of 6 and 8 at\% SIMFUEL yielded a cubic phase, and that the time to convert UO\textsubscript{2} to U\textsubscript{3}O\textsubscript{8} increased with simulated burnup at 250 °C [12]. Talip et al. studied the air oxidation of La-doped UO\textsubscript{2} at 500 K and concluded that La doping causes a lattice expansion which increases diffusion of O\textsuperscript{2−} ions in the UO\textsubscript{2} matrix, leading to its prompt oxidation in air, which stops after the formation of an M\textsubscript{2}O\textsubscript{3} phase [13]. You et al. showed that the weight gain due to oxidation of 15 wt\% Gd\textsubscript{2}O\textsubscript{3} doped UO\textsubscript{2} at 350 °C is only half that of the un-doped UO\textsubscript{2} [14]. Kim et al. studied
the effect of Gd$^{3+}$ as a dopant in UO$_2$ on its oxidation using thermogravimetry and XRD analysis. The degree of oxidation from UO$_2$ to U$_3$O$_7$ was found to decrease linearly with increasing Gd content, suggesting the Gd dopant can slow down the initial oxidation kinetics from UO$_2$ to U$_4$O$_9$ and prevent the complete oxidation to U$_3$O$_7$ [15]. Razdan and Shoesmith showed that the electrochemical oxidation/dissolution mechanism of Gd-doped UO$_2$ is similar to that of SIMFUEL, although the overall reactivity is lower. It was proposed that this could be attributed to the presence of Gd$^{3+}$O$_2$ (O$_2^-$: oxygen vacancy) clusters which reduce the availability of the (O$_2^-$)s required to accommodate excess O$^{2-}$ ions when oxidation occurs [16,17].

Since there has been a continuous trend toward higher in-reactor fuel burnup [18], the extent of doping and its influence on fuel reactivity under waste disposal conditions is becoming more important. In this study, a series of (U$_{1-y}$Gd$_y$)O$_2$ materials ($y=0$, $0.01$, $0.03$, $0.05$, $0.07$ and $0.10$) were synthesized, characterized by XRD and Raman spectroscopy, and the reactivity of the (U$_{1-y}$Gd$_y$)O$_2$ matrix investigated electrochemically. Since the key groundwater constituents likely to influence fuel dissolution are HCO$_3^-/CO_2^{2-}$, which will increase UO$_2^{2+}$ solubility by complexing UO$_2^{2+}$ [6], these studies were conducted in solutions containing HCO$_3^-/CO_2^{2-}$.

2. Experimental

2.1. Materials and preparation

U$_{1-y}$Gd$_y$O$_2$ pellets with various compositions ($y=0$, $0.01$, $0.03$, $0.05$, $0.07$ and $0.10$) were synthesized using a conventional solid-state process involving the mixing of oxide powders. Appropriate amounts of UO$_2$ and Gd$_2$O$_3$ (Aldrich, >99.99%) powder were mixed and thoroughly blended in an agate mortar. The blended powders were then pressed into a disk-shaped pellet and sintered at 1700°C for 18 h in a reducing atmosphere with flowing hydrogen. The sintered pellets were then cooled to room temperature in flowing hydrogen after annealing in the same atmosphere at 1200°C for 12 h.

2.2. X-ray diffraction

X-ray diffraction (XRD) patterns were measured with a Bruker D8 Advance X-ray Diffractometer using Cu K$_\alpha$ radiation at room temperature. XRD data were collected from several locations on the sintered pellets to confirm the homogeneity in structure. The lattice parameters of the solid solution samples were determined over the 2θ range from 20° to 120° using a 0.02° step size. The lattice parameters of the samples were calculated by a refinement process using the TOPAS program (Bruker Analytical X-Ray Systems) with the Fm$\bar{3}$m space group.

2.3. Raman Spectroscopy

The Raman spectroscopic measurements were carried out with an ANDOR Shamrock SR500i spectrometer, with active vibrations excited using a He-Ne laser with a wavelength of 632.8 nm. The laser, with a power of ~5 mW, was focused onto the pellets using an Olympus microscope with a 50-fold magnification lens. This laser power was confirmed to be low enough to prevent surface oxidation of the pellets, due to local heating effects by the laser beam. Raman spectra were acquired over the wavenumber range from 400 to 1200 cm$^{-1}$ using an exposure time of 300 s. Spectra were collected from different locations on the surface of pellets to confirm their reproducibility and the homogeneity of composition.

2.4. Electrochemical procedures

Experiments were performed in a standard three-electrode cell. A commercial saturated calomel reference electrode (SCE) (+0.242 V, 25°C vs. standard hydrogen electrode (SHE)) was used,

![Fig. 1. SEM images recorded on U$_{1-y}$Gd$_y$O$_2$ specimens (a, y = 0; b, y = 0.01; c, y = 0.03 and d, y = 0.07).](image-url)
and a Pt wire with a spot-welded Pt foil was employed as the counter electrode. All potentials were quoted on the SCE scale. All electrochemical experiments were carried out using a CHI-600D potentiostat to control applied potentials and record current responses. IR compensation was employed to compensate voltage drops due to ohmic resistance in the electrodes. Prior to experiments, electrodes were prepared by polishing using wet 3000 grit SiC paper and rinsed with distilled deionized water. Subsequently, the electrodes were electrochemically reduced at −1.2 V for 5 min (vs. SCE) to remove any air-formed oxides or organic contaminants present on the surface.

2.5. Solution preparation

Solutions were prepared using distilled deionized water (resistivity ρ = 18.2 MΩ•cm) purified using a Millipore Milli-Q plus unit which removes organic and inorganic impurities. The base electrolyte was 0.1 mol L⁻¹ NaCl (Aldrich). The HCO₃⁻/CO₃²⁻ concentrations were adjusted with Na₂CO₃ and NaHCO₃ (Aldrich). The total carbonate concentration ([CO₃⁻] = [HCO₃⁻] + [CO₃²⁻]) was 0.05 mol L⁻¹ with the pH maintained constant at 10 using an Orion model 720A pH meter. Prior to an experiment, the solution in the cell was purged with Ar-gas (Shinhan Gas) for an hour and purging was then maintained throughout the experiment.

3. Results and Discussion

3.1. Surface morphology

Fig. 1 shows that the morphology of the surface for U₁₋ₓGdₓO₂ changes as the doping level increases from 0 to 3%, but then remains unchanged up to 7%. Also a number of voids are visible on the surface, introducing the possibility that the reactivity may not be totally uniform.

3.2. XRD Analysis

The XRD patterns (not shown here) show that the specimens retain the fluorite structure with no XRD peaks observed for the monoclinic Gd₂O₃ impurity [19]. Fig. 2 compares the lattice parameter as a function of Gd determined in this study with the values measured by Kim [15], Ohmichi [20] and Baena [21]. The lattice parameter decreases as the Gd doping level increases. The lattice contraction could be caused by one or other (or both) of two charge compensation mechanisms: one involves the creation of U⁺ (the radius of the U³⁺ ion (r = 0.088 nm) is smaller than that of the U⁴⁺ ion (0.1001 nm)), and the other the formation of (O₂⁻)ₙ (O₂⁻:

<table>
<thead>
<tr>
<th>y</th>
<th>0</th>
<th>0.01</th>
<th>0.05</th>
<th>0.10</th>
</tr>
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<tbody>
<tr>
<td>n in (U₁₋ₓGdₓO₂)²⁻</td>
<td>0</td>
<td>0.01</td>
<td>0.05</td>
<td>0.10</td>
</tr>
<tr>
<td>n in (U₁₋ₓGdₓO₂)²⁻</td>
<td>0</td>
<td>0.005</td>
<td>0.025</td>
<td>0.05</td>
</tr>
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</table>

Table 1: The formation of U⁺ and oxygen vacancies to neutralize the charge introduced by Gd doping.

* y as in U₁₋ₓGdₓO₂, indicating the Gd doping level.
* Assuming the creation of U⁺ is the only charge neutralization feature introduced by doping.
* Assuming the creation of oxygen vacancies is the only charge neutralization feature introduced by doping.

The oxygen vacancy) (Table 1). He et al. studied the influence of fission product doping on the structure of SIMFUELS [22]. As the doping level increased, the X-ray photoelectron spectroscopic (XPS) data indicated an increase in U⁺ content, while deconvolution of the Raman spectra indicated the increasing formation of RE³⁺-O₂⁻ clusters, suggesting either both charge compensation mechanisms are operative or they cannot be distinguished in SIMFUELS. Compared with the results of Ohmichi [20] and Baena [21], this work yields a slightly larger lattice parameter (Fig. 2), which could be attributable to a slight hypo-stoichiometry of our specimens [20]. According to the relationship between the degree of hypo-stoichiometry (x in U₁₋ₓGdₓO₂₋ₓ) and the lattice parameter (a) proposed by Ohmichi [20] (Eq. (1)),

\[
\frac{da}{dx} = 0.024 ± 0.006 \text{ nm}
\]

the degree of hypo-stoichiometry (x in U₁₋ₓGdₓO₂₋ₓ) in our specimens could be between 0.012 (y = 0) and 0.025 (y = 0.1).

3.3. Raman spectroscopy

Raman spectroscopy has been commonly used to investigate the structure of the U-O system [13,17,22–26]. UO₂ has a cubic fluorite structure and belongs to the space group O₆(Fm₃m) and should generate a triply degenerate Raman active (T₂g₃) mode at ~445 cm⁻¹, assigned to the O-U stretch, and a band at ~1150 cm⁻¹, assigned as an overtone (2LO) of the first order L-O phonon (~575 cm⁻¹). It has been suggested that the band at ~1150 cm⁻¹ can be taken as a fingerprint for the quasi-perfect fluorite structure, since its intensity decreases considerably as the defect structure develops, due to increasing non-stoichiometry. [25].

Fig. 3 shows the Raman spectra of the U₁₋ₓGdₓO₂ specimens (y = 0.01, 0.05 and 0.07). While all four exhibit a similar structure, the relative peak intensities differ considerably. For UO₂ (Fig. 3A), the peaks at 450 cm⁻¹ and 1150 cm⁻¹ are dominant compared to...
the broad band between 500–700 cm\(^{-1}\), indicating the lattice is relatively defect free. As the extent of Gd doping increases, the relative intensity of the two bands at 445 cm\(^{-1}\) and 1150 cm\(^{-1}\) decrease with respect to the broad band (between 500–700 cm\(^{-1}\)), which has been attributed to UO\(_2\) lattice damage, due to the formation of the defects caused by doping \([22]\).

Li et al. \([27]\) studied the defect sites for a series of dopants in Ce\(_{0.8}\)M\(_{0.2}\)O\(_2\) solid solutions (CeO\(_2\) has a similar fluorite lattice to UO\(_2\)) using Raman spectroscopy, and investigated the effects of different valence states and ionic radii of the dopants on the spectral features of these materials. A peak at \(\sim 560 \text{ cm}^{-1}\), observed on Ce\(_{0.8}\)Pr\(_{0.2}\)O\(_2\) was assigned to the creation of O\(_{\text{v}}\) due to the difference in ionic valence states between Pr\(^{3+}\) (n = 3–4) and Ce\(^{4+}\), Pr\(^{3+}\) having a similar average ionic radius to Ce\(^{4+}\). A peak at \(\sim 600 \text{ cm}^{-1}\), observed on Ce\(_{0.8}\)Zr\(_{0.2}\)O\(_2\) was assigned to the formation of a ZrO\(_2\)-type complex, Zr\(^{4+}\) (0.084 nm) and Ce\(^{4+}\) (0.097 nm) having very different ionic radii. For Ce\(_{0.8}\)Gd\(_{0.2}\)O\(_2\), two bands are observed simultaneously at approximately 560 and 600 cm\(^{-1}\), suggesting the presence of both defect structures when both the oxidation state and the ionic radius of the dopant differ from that of the matrix cation. He et al. studied the defect structures of hyper-stoichiometric U\(_{2+x}\) using Raman spectroscopy \([23]\), and demonstrated that a band at 630 cm\(^{-1}\) became increasingly more prominent as the O defect content increased. This 630 cm\(^{-1}\) band was assigned to the A\(_{1g}\) stretch due to the formation of cuboctahedral clusters. This assignment was confirmed by Desgranges et al. \([24]\), Talip et al. \([13]\) studied the La doped UO\(_2\) and assigned the 630 cm\(^{-1}\) band to the formation of U\(_4\)O\(_9\) under oxidation conditions.

The deconvolution of the broad band in our spectra is shown in Fig. 4. The 450 cm\(^{-1}\) peak is treated as Lorentzian while those at 540, 575 and 620 cm\(^{-1}\) are treated as Gaussian. The peak at 540 cm\(^{-1}\) is not observed in UO\(_2\) (Fig. 4A) but increases as the doping level increases (Fig. 4B to D), confirming it can be assigned to the creation of Gd\(^{3+}\)-oxygen vacancy (O\(_{\text{v}}\)) clusters. The presence of O\(_{\text{v}}\) in UO\(_2\) is consistent with the calculations of Park \([28]\), and the observations of Desgranges, who attributed a peak at this wavenumber (recorded on Nd-doped UO\(_2\)) to a local phonon mode associated with O\(_{\text{v}}\)-induced lattice distortion \([29]\). The intensity of the peak at 620 cm\(^{-1}\) also increases as the doping level increases, suggesting the possible presence of MO\(_2\)-type complexes as claimed by Li et al. \([27]\) when Gd was the dopant. As noted above the peak at 575 cm\(^{-1}\) is due to the first order L-O phonon and is associated with the close to perfect fluorite lattice.

Fig. 5 shows the area ratios of the peaks at 540, 575 and 620 cm\(^{-1}\) versus the T\(_{2g}\) peak (450 cm\(^{-1}\)). The ratio between the 540 cm\(^{-1}\) peak and the T\(_{2g}\) peak increases as the doping level increases up to 7\%, and then decreases. Since the T\(_{2g}\) peak is characteristic of the undisturbed fluorite lattice and the 540 cm\(^{-1}\) peak is related to the creation of O\(_{\text{v}}\) associated with the Gd\(^{3+}\) doping, this suggests the formation of O\(_{\text{v}}\) becomes less important than the charge compensation mechanism when the doping level
is high; i.e., 10%. The area ratio between the 620 cm\(^{-1}\) peak and the \(T_{2g}\) peak increases as the doping level increases, suggesting an increase in importance of MO\(_8\)-type complexes as the lattice is disturbed by the Gd\(^{III}\) doping. The alternative assignment of a peak in this spectral region to a hyperstoichiometric cuboctahedral cluster can be ruled out in our specimens, which are close to stoichiometric and possibly slightly hypostoichiometric. The peak at 575 cm\(^{-1}\) was shown to be independent of doping level in a series of SIMFUELs investigated previously [22]. However, in this study, the area ratio \((A_{575}/A_{450})\) increases as the doping level increases, most likely due to a breakdown in selection rules as the presence of defects increases, making the forbidden first order L-O Raman scattering mode (575 cm\(^{-1}\)) allowed [23].

Whether or not MO\(_8\)-type clusters are present is uncertain since deconvolution of the Raman spectra was found to be very sensitive to the peak shape adopted when fitting the spectra. Fig. 6 compares the deconvoluted Raman spectra for our \(U_{0.93}Gd_{0.07}O_2\) specimen obtained using different assumed peak shapes. While the 450 cm\(^{-1}\) peak is treated as Lorentzian in both fits, the peaks at 540, 575 and 620 cm\(^{-1}\) are assigned as Gaussian peaks in Fig. 6A and Lorentzian

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**Fig. 4.** Deconvoluted Raman spectra of \(U_{1-x}Gd_xO_2\) specimens (a, \(y = 0\); b, \(y = 0.01\); c, \(y = 0.03\) and d, \(y = 0.07\)).

**Fig. 5.** Area ratios of the Raman peaks recorded at 540 cm\(^{-1}\), 575 cm\(^{-1}\) and 620 cm\(^{-1}\) versus the \(T_{2g}\) peak at 450 cm\(^{-1}\) as a function of the Gd doping level.
peaks in Fig. 6B. In the latter case (Fig. 6B) the 620 cm\(^{-1}\) peak becomes marginal.

3.4. Electrochemical study

When perfectly stoichiometric, UO\(_2\) is best described as a Mott-Hubbard insulator. The introduction of electronic conductivity requires promotion of electrons from the occupied U \(5f\) level to the conduction band, which is a strongly activated process with a low probability at room temperature. However, replacement of a fraction of the U\(^{IV}\) ions with RE\(^{III}\) ions requires further ionization of the remaining uranium ions (to U\(^V\)) or the creation of oxygen vacancies (O\(^v\)) to maintain overall charge balance (Table 1). The former creates mobile holes in the U \(5f\) band, resulting in an increased conductivity [30]. Table 2 summarizes the total cell resistances for the four electrodes investigated, with the resistance being effectively that of the U\(_{1-x}\)Gd\(_x\)O\(_2\) electrode. As expected, the undoped UO\(_2\) has a relatively high resistance compared with the U\(_{0.99}\)Gd\(_{0.01}\)O\(_2\) electrode. However, increased doping leads to only a marginal further increase in conductivity. A possible explanation for this is that the expected increase in conductivity due to doping is offset by the lattice disorder introduced by Gd\(^{III}\)-O\(^v\) clustering. However, Fig. 5 suggests the formation of O\(^v\) becomes less important as the doping level increases up to 10\%, suggesting the formation of O\(^v\) is only part of the reason for the marginal increase in conductivity. A second possible explanation based on impedance measurements [31] would be that, there are two conductivity pathways on the Gd-doped UO\(_2\) specimens, matrix and grain boundary. According to Kubo et al. [31], while matrix conductivity increases linearly with increased doping, the grain boundary conductivity decreases, the latter being attributed to segregation of Gd to the grain boundaries, leading to the formation of a potential barrier against the migration of holes in the U\(5f\) level. These conflicting effects could result in the insensitivity of the conductivity to doping [31]. Even though impedance spectroscopy is widely used in testing the conductivity of solid-state materials [31–33], the adoption of an electrical equivalent circuit involving two time constants in series to represent grain and grain boundary conductivities is suspect. Faber et al. [34] proposed that doping could cause the appearance of percolation paths associated with a low activation energy, while the creation of deep traps because of multiple trapping could lead to an increase of the activation energy.

Table 2

<table>
<thead>
<tr>
<th>Electrode</th>
<th>Resistance (ohms) in 0.1 M NaCl</th>
<th>Resistance (ohms) in 0.1 M NaCl and 0.05 M Na(_2)CO(_3)/NaHCO(_3)</th>
</tr>
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<tbody>
<tr>
<td>UO(_2)</td>
<td>261.6</td>
<td>245.1</td>
</tr>
<tr>
<td>(U(<em>{0.99})Gd(</em>{0.01}))O(_2)</td>
<td>53.1</td>
<td>38.6</td>
</tr>
<tr>
<td>(U(<em>{0.95})Gd(</em>{0.05}))O(_2)</td>
<td>50.8</td>
<td>37.9</td>
</tr>
<tr>
<td>(U(<em>{0.90})Gd(</em>{0.10}))O(_2)</td>
<td>51.2</td>
<td>37.4</td>
</tr>
</tbody>
</table>

Fig. 6. Deconvoluted Raman spectrum of U\(_{0.99}\)Gd\(_{0.01}\)O\(_2\). The peaks at 540, 575 and 620 cm\(^{-1}\) are treated as Gaussian peaks in (A) and Lorentzian peaks in (B).
energy. These compensating effects offer an alternative explanation for the insensitivity of conductivity to the doping level for the Gd-doped UO$_2$ specimens.

3.4.1. Cyclic Voltammetry

Fig. 7 shows a series of CVs recorded on the undoped and Gd$_{1-x}$-doped UO$_2$ electrodes. As observed for SIMFUEL [35] and previously for Gd-doped UO$_2$ [16], the electrodes exhibit similar stages of oxidation and reduction. On the positive scan, the current in region 1 can be attributed to the oxidation of a thin surface layer to a mixed U$^{IV}$/U$^{V}$ oxide (U$_{1-x}$,$^4$O$_2$O$_{2-x}$), with a thickness limited by diffusion of O to subsurface locations. Oxidation at higher potentials (region 2 in Fig. 7) was attributed to the oxidation of this U$_{1-x}$,$^4$O$_2$O$_{2-x}$ layer to U$^{V}$, most of which will dissolve as UO$_2^{2+}$ complexed by HCO$_3$/$\text{CO}_3^{2-}$. On the reverse scan, the extent of surface oxidation (not including the U dissolved) can be gauged by the size of the reduction peak 3. Comparison of the CVs shows that the reactivity in region 1 is insensitive to the doping level and only decreased in region 2 at the highest doping level (y = 0.1). Similarly, on the reverse scan, the current associated with the reduction of the surface does not vary significantly with doping level.

3.4.2. Potentiostatic Polarization

Since CVs are performed rapidly, they may not faithfully capture the differences in reactivity levels due to doping. These differences may be more realistically assessed under steady-state conditions. Fig. 8 shows potentiostatic polarization curves recorded on the U$_{0.95}$Gd$_{0.05}$O$_2$ electrode for potentials at the positive end of region 1 (0.1 V) and in region 2 (0.2 V to 0.5 V). At the two lowest potentials (0.1 V and 0.2 V), the current decreases linearly (on the logarithmic scale) especially at the lowest potential. This is consistent with a loss in surface reactivity associated with the formation of a U$_{1-x}$,$^4$O$_2$O$_{2-x}$ thin surface layer. At longer times, the current continues to decrease at 0.1 V but begins to stabilize at a steady-state value at 0.2 V, indicating the onset of region 2; i.e., the conversion of this layer to soluble U$^{IV}$O$_2^{2-}$. At 0.3 V and higher, a steady-state current independent of potential is much more rapidly achieved. As previously shown for 6 wt% Gd-doped UO$_2$, this potential-independent current can be attributed to the electrochemical formation of a U$^{IV}$O$_2$CO$_3$ surface layer (Eq. (2)),

$$U_{1-x}^4O_2O_{2-x} + CO_3^{2-} \rightarrow U^{IV}O_2CO_3$$

(2)

whose subsequent dissolution is chemically-controlled (Eq. (3)).

$$U^{IV}O_2CO_3 + CO_3^{2-} \rightarrow U^{IV}O_2(CO_3)^{2-}$$

(3)

Fig. 9 shows the steady-state currents recorded in region 2 (Fig. 7) as a function of the Gd content of the matrix. At low Gd contents (up to $\sim y = 0.03$ to 0.05), the current, which is due to steady-state dissolution (as U$^{IV}$O$_2(CO_3)^{2-}$) is either independent of
the doping level (0.2 V) or increases slightly (at 0.3 V to 0.5 V). For $y > 0.05$, the current decreases with further increases in Gd content. Perhaps a more reliable measure of the influence of Gd-doping can be obtained by integrating the potentiostatic currents measured over the full 60 minute period. The total anodic charges obtained in this manner are shown in Fig. 10. For anodic oxidation at a potential in region 1 (0.1 V), there is no observable influence of Gd content on the charge accumulated. This confirms that the formation of the thin $U_{1-y}^{5+} Gd_{y}^{3+} O_{2}$ is not measurably influenced by Gd-doping. At a slightly higher applied potential (0.2 V), when dissolution as $U^{IV}O_{2}^{2-}(CO_{3})_{2}^{2-}$ is occurring, the trends observed for steady-state currents are confirmed, the charge either remaining constant or increasing slightly over the doping range 0.01 $\leq y \leq 0.05$ and then decreasing with $y$ at higher doping levels ($y > 0.05$).

These effects can be interpreted based on the XRD and Raman spectroscopic observations. The XRD data shows that an increase in doping level leads to a contraction of the UO$_2$ lattice. This would be expected to inhibit the incorporation of O$^{2-}$ ions into interstitial sites (O$_{i}$) and their transport to sub-surface locations in the UO$_2$ fluorite lattice, which should inhibit the oxidation process. By contrast, the increase in Gd$^{III}$ content should also lead to an increase in the number of O$_{v}$ which should increase the rate of oxidation by providing additional sites for the inclusion of O$_{i}$.

The changes in current and charge with Gd content suggest a competition between these two effects. The slight increase in current and charge could be taken to indicate a slight increase in anodic reactivity (for the second stage of oxidation) at low doping levels, while the clear decrease in reactivity at higher doping levels could reflect the lattice contraction which is marked at the highest levels. It is also possible that the clear decrease at higher doping levels, while only small, demonstrates the formation of Gd$^{III}$O$_{v}$ clusters, as indicated by the changes in the Raman spectra with doping, a process that would also retard oxidation by decreasing the availability of the O$_{i}$ required to accommodate additional O$_{i}$.

4. Conclusions

A series of ($U_{1-y} Gd_{y}$)$_2$O$_2$ materials ($y = 0.01, 0.03, 0.05, 0.07$ and $0.10$) were characterized by XRD and Raman spectroscopy to study the influence of Gd$^{III}$ doping on the structure of ($U_{1-y} Gd_{y}$)$_2$O$_2$ solid solutions. XRD shows that the materials retain a fluorite lattice, which contracts as the Gd content increases up to 10%. Raman spectroscopy shows that Gd$^{III}$ doping distorts the fluorite lattice structure, leading to the formation of oxygen vacancies (O$_{v}$).
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